CLAIMS

- 1. A poll-shing solution for metal comprising
 (1) an additive which permits chemical mechanical
 polishing to be darried out without solid abrasive grains,
- (2) an oxidizing agent and (3) water.
 - 2. A polishing sofution for metal comprising
- (1) an oxidizing agent, (2) an oxidized-metal dissolving agent, (3) a metal etching rate inhibitor, and (4) water.

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